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## Nature of the acceptor responsible for *p*-type conduction in liquid encapsulated Czochralski-grown undoped gallium antimonide

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Acceptors in liquid encapsulated Czochralski-grown undoped gallium antimonide (GaSb) were studied by temperature dependent Hall measurement and positron lifetime spectroscopy (PLS). Because of its high concentration and low ionization energy, a level at  $E_V$ +34 meV is found to be the important acceptor responsible for the p-type conduction of the samples. Two different kinds of  $V_{Ga}$ -related defects (lifetimes of 280 ps and 315 ps, respectively) having different microstructures were characterized by PLS. By comparing their annealing behaviors and charge state occupancies, the  $E_V$ +34 meV level could not be related to the two  $V_{Ga}$ -related defects. © 2004 American Institute of Physics. [DOI: 10.1063/1.1773934]

Gallium antimonide GaSb is a direct band-gap semiconductor suitable for fabricating high-frequency electronic devices and optoelectronic devices operating in the 2–4  $\mu m$  wavelength region. GaSb is also the suitable substrate for growing various III–V compounds with bandgaps varying over a wide range from 0.3–1.58 eV (i.e., 0.8–4.3  $\mu m$ ). Undoped GaSb is usually p-type material (p  $\sim 10^{16}$ – $10^{17}$  cm $^{-3}$ ) with a residual acceptor that is doubly ionizable and related to Ga in excess. This acceptor has been usually associated with the Ga vacancy or the  $V_{Ga}Ga_{Sb}$  complex,  $^{1.2}$  although some reports have suggested a structure of  $Ga_{Sb}$ .  $^{3.4}$ 

Positron annihilation spectroscopy is a useful probe for studying vacancy-type defects in semiconductors.<sup>5-9</sup> In the previous positron lifetime studies, 10,11 we have observed a ~315 ps lifetime component in heavily Zn-doped and undoped p-type GaSb materials. This component was attributed to the V<sub>Ga</sub>-related defect. This defect annealed at temperatures of 300-400 °C. In contrast, the hole concentrations observed in the undoped samples show no significant change  $(p \sim 10^{17} \text{ cm}^{-3})$  with annealing temperature up to 500 °C. This implies that, at least for the samples annealed at  $T_a$ ≥300 °C, V<sub>Ga</sub> related defect is not the acceptor responsible for the p-type conduction. The present study aims at investigating the identity of the residual acceptor and the role of the V<sub>Ga</sub>-related defect in determining the undoped material's hole concentration by performing temperature dependent Hall (TDH) and positron lifetime spectroscopy (PLS) measurements.

Samples of  $1\times1$  cm² were cut from the liquid encapsulated Czochralski (LEC)-grown undoped p-type GaSb wafers. The annealing steps were performed in forming gas (N<sub>2</sub>:H<sub>2</sub>=80%:20%) for a period of 30 min. The TDH measurements were performed with the Accent HL5500 system. The positron lifetime spectrometer is a conventional fast–fast system having a full width at half maximum resolution of 200 ps or 230 ps. Each of the PLS spectra contained  $4\times10^6$  events. The positron lifetime spectra were decomposed by the POSITRONFIT code, <sup>12</sup> which considered the spectrum

to be of the form of  $S(t) = \sum I_i \exp(-t/\tau_i)$ , where  $I_i$  and  $\tau_i$  are the intensity and the characteristic lifetime of the corresponding annihilating states.

TDH measurements (4 K-300 K) were performed on nonirradiated and electron  $(e^{-})$ -irradiated (1.7 MeV and 10<sup>17</sup> cm<sup>-2</sup>) undoped samples. From the charge neutrality condition, the hole concentration p, the electron concentration n, the effective donor concentration  $N_D$ , the concentrations  $N_{Ai}$ , and the ionization energies  $E_{Ai}$ , of the acceptors are given by:  $p + N_D = n + \sum N_{Ai} \{1 + g \exp[(E_{Ai} - E_F)/(kT)]\}^{-1}$ . This equation was used to fit the TDH data with n=0 and g=4. Four acceptors A1, A2, A3, and A4 were detected in all of these samples having the following ionization energies and  $E_{\rm A1} = 4-10 \text{ meV}, \qquad C_{\rm A1} = 2 \times 10^{13} - 1$ concentrations,  $imes 10^{15} \ {
m cm^{-3}}; \ E_{
m A2} = 31 - 35 \ {
m meV}, \ C_{
m A2} = 0.2 - 2.3 \times 10^{18} \ {
m cm^{-3}}; \ E_{
m A3} \sim 89 \ {
m meV}, \ C_{
m A3} \sim 10^{16} \ {
m cm^{-3}}, \ {
m and} \ E_{
m A4} \sim 120 \ {
m meV}, \ C_{
m A4}$  $\sim 10^{16}$  cm<sup>-3</sup>. Because of its low concentration, A1 could not be the dominant acceptor providing the p-type conductivity. A3 and A4 are also unlikely candidates due to their large ionization energies and low concentration. The A2 acceptor remains as the most important acceptor. Hole and the A2 concentrations are shown as a function of the annealing temperature in Fig. 1. They remain unchanged in the nonirradiated sample in the range of  $1.8-2\times10^{17}$  cm<sup>-3</sup>. For the irradiated sample, however, the A2 concentration increases sharply to  $2.2 \times 10^{18}$  cm<sup>-3</sup> for annealing above 300 °C.

In our previous PLS study on the nonirradiated undoped GaSb materials, <sup>11</sup> the lifetime spectra were well described by the single defect model ( $\tau_d \sim 315$  ps) for samples annealed at  $T_a \leq 300$  °C. For those samples annealed at  $T_a \leq 300$  °C, a single component fit, attributed to the V<sub>Ga</sub>-related defect, gave a good description. Here, we report on a PLS study of e<sup>-</sup>-irradiated undoped GaSb. <sup>13</sup> The main finding is that a single defect trapping model can represent the spectra of samples annealed at  $T_a < 300$  °C, but fails for spectra annealed at  $T_a < 300$  °C. The most likely explanation for such an observation is that at  $T_a < 300$  °C, the 280 ps and the 315 ps components coexist, whereas for  $T_a < 300$  °C, only the 280 ps survives with the 315 ps component annealed out. As the samples maintain their p-type conductivity upon annealing, the 280 ps lifetime component is again attributed to

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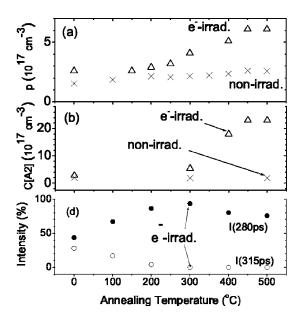


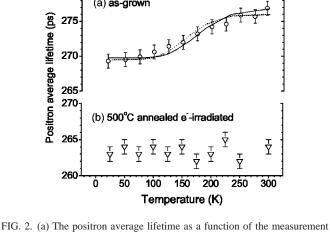
FIG. 1. (a) Hole concentrations of the nonirradiated and e-irradiated undoped GaSb samples as a function of the annealing temperature. (b) Concentration of the acceptor A2 ( $E_V$ +34 meV) of the nonirradiated and the e-irradiated undoped GaSb samples as a function of the annealing temperature. (c) Fitted intensities of the two Ga vacancy-related defects  $V_{Ga,280~ps}$  and  $V_{Ga,315~ps}$  as a function of the annealing temperature.

a  $V_{Ga}$ -related defect. (The  $V_{Sb}$  defect is expected to be positively charged and unable to trap positrons.)

Since a free three-component fit on the lifetime spectra is difficult, the spectra of the irradiated sample annealed at  $T_a \le 300$  °C were fitted by fixing the two defect components at 280 ps and 315 ps. The fitted intensities of the two defect components are shown in Fig. 1(c). From the figure, the annealing of the 315 ps component is clearly seen at 300 °C. It is also observed that the 280 ps component intensity increases with annealing temperature, reaching a maximum at  $T_a = 300$  °C before slightly decreasing.

One speculation is that the two different defect lifetimes may originate from the same  $V_{\text{Ga}}\text{-related}$  defect having different charge states and degrees of relaxation, a change in charge state occupancy being rendered by a change in the Fermi-level position incurred upon annealing. This proposal is ruled out since in the non-irradiated sample, the VGA, 315 ps defect anneals while the TDH measurements show no significant change in the Fermi level. Another possibility is that the two positron lifetimes originate from two  $V_{\text{Ga}}\text{-related}$  defects having different microstructures. However, the detailed structures of the two  $V_{\text{Ga}}\text{-related}$  defects are not known from the present data and this possibility would require further investigations.

PLS measurements (20 K–300 K) carried out on the 500 °C e<sup>-</sup>-irradiated sample show an unchanging mean positron lifetime and a defect lifetime ( $\sim$ 280 ps) and its intensity ( $\sim$ 76%) which are temperature independent (shown in Fig. 2). This implies that the V<sub>Ga,280 ps</sub> defect center in the 500 °C annealed irradiated sample is neutral and its charge state occupancy does not change from 20 K to 300 K. On the other hand, the TDH determined Fermi level  $E_F$ – $E_v$ , shifted from 17 meV to 79 meV as the temperature changed from 20 K to 300 K, implying that the V<sub>Ga,280 ps</sub> related defect center cannot be associated with the A2 acceptor ( $\sim$ 34 meV).



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FIG. 2. (a) The positron average lifetime as a function of the measurement temperature for the as-grown undoped GaSb sample. The solid line is the model fit with no positron shallow trap. The dotted line is the modeled curve with the shallow trap's concentration and binding energy equal to  $2 \times 10^{17}$  cm<sup>-3</sup> and 10 meV, and E(0/-)=70 meV and  $C[V_{Ga,315}]=8 \times 10^{16}$  cm<sup>-3</sup>. (b) The positron average lifetime as a function of the measurement temperature for the 500 °C annealed e-irradiated sample.

It is similarly possible to rule out any correlation between the 315 ps  $V_{Ga}$ -related defect and A2. For the nonirradiated sample, the measured hole concentration (and thus also  $E_F$ – $E_V$ ) remains constant at  $\sim 2 \times 10^{17}$  cm<sup>-3</sup> for the whole annealing temperature range. This implies that the charge state occupancy of the defect  $V_{Ga}(315 \text{ ps})$  does not change with respect to annealing temperature. It thereby follows that the annealing of the 315 ps component in the nonirradiated sample at 300 °C must be due to the thermal annealing out of the defect. Moreover, since there is no significant change in the hole or A2 concentrations accompanying the 300 °C annealing, the  $V_{Ga}$ -related (315 ps) defect cannot be an important acceptor in determining the electrical property of the material.

Temperature dependent PLS measurements carried out GaSbsamples as-grown undoped from 20 K to 300 K (corresponding to  $E_F - E_V$ =20 meV-72 meV) show the average lifetime increases with temperature (Fig. 2). This behavior may be due to the ionization of the V<sub>Ga</sub>-related (315 ps) defect and/or the existence of a positron shallow trap. A model consisting of a shallow trap and the V<sub>Ga</sub>-related (315 ps) were constructed to fit for the positron average lifetime data. The charge state occupancy for the V<sub>Ga</sub>-related defect is obtained from:  $[V_{Ga,315 ps}]/[V_{Ga,315 ps}^{Q+1}] = (g_Q/g_{Q+1}) \exp[-(E_i-E_F)/(kT)],$ where  $E_i$  is the corresponding ionization energy, keeping the total concentration of defect  $V_{\text{Ga},315\ ps}$  constant. The positron trapping rate into  $V_{Ga,315 ps}$  is then given by:  $\kappa_Q = \mu_Q [V_{Ga,315 ps}^Q]^{.5,6}$  The specific trapping coefficient of  $V_{Ga,315 ps}^{Q}$  (i.e.,  $\mu_Q$ ) is taken to be constant for the neutral vacancy and follows  $\mu \sim T^{-0.5}$  law for the negatively charged vacancy.<sup>5,6</sup> The positron dynamics were described by standard rate equations for trapping into the  $V_{Ga,315~ps}$  defect and the shallow trap.<sup>5,6,10</sup> The resulting four component lifetime spectra then give the average positron lifetime  $\tau_{\text{ave}} = \sum_{i=1}^{4} I_i \tau_i$ . Since, as demonstrated, the most abundant acceptor A2  $[C(A2) \sim 2 \times 10^{17} \text{ cm}^{-3}]$  is not related to the two  $V_{Ga}$ -related defects, it is itself, in its ionized state, a possible candidate for a positron shallow trap. Although its binding energy is not accurately determined, reasonable values ranging from

 $\sim$  34 meV). How accurately determined, reasonable values ranging from the values ranging from Downloaded 08 Nov 2006 to 147.8.21.97. Redistribution subject to AIP license or copyright, see http://apl.aip.org/apl/copyright.jsp

10 meV to 100 meV have been employed in fitting. The details of fitting and the values of other parameters can be found in Ref. 10. Good fittings to the data could be obtained with the shallow trap concentration of  $2\times10^{17}~\rm cm^{-3}$ , and the  $V_{Ga,315~ps}$  parameters lying in the range of E(0/-) =70–85 meV and  $[V_{Ga,315~ps}]$ =5–8 $\times10^{16}~\rm cm^{-3}$ . The shallow trap concentration is in good agreement with the C(A2). It is noted that the  $V_{Ga,315~ps}$ 's ionization energy and concentration coincide well with those of the A3 acceptor (~89 meV and  $6.5\times10^{16}~\rm cm^{-3}$ ). This concurs with the 300 °C annealing temperature of  $V_{Ga,315~ps}$ , at which the A3 concentration also dramatically decreases to 1.2  $\times10^{16}~\rm cm^{-3}$ . The A3 acceptor is thus believed to be related to the (0/–) transition of  $V_{Ga,315~ps}$ .

Having concluded that the two identified V<sub>Ga</sub>-related defects are not associated with the A2 acceptor, it is interesting to inquire as to the identity of the A2 defect. From firstprinciple calculations, Hakala et al.3 have shown that the  $Ga_{Sb}$  acceptor has an ionization level at  $E_V+0.04$  eV, which is close to the presently observed 34 meV ionization energy of the A2 acceptor. In the same study, it was pointed out the formation energy of the GaSb antisite was found to be the lowest among the other native defects and thus it should be an abundant defect in the GaSb material. Based on the experimental Hall data and thermodynamic considerations, Shaw<sup>4</sup> also argued that the Ga<sub>Sh</sub> should be the residual acceptor of GaSb. Our present findings that the acceptor A2, with ionization energy of  $\sim$ 34 meV, is the most important acceptor responsible for the p-type conduction is thus consistent with the picture of A2 being the Ga<sub>Sb</sub> antisite.

In conclusion, we have investigated the acceptors in undoped LEC-grown GaSb. The 34 meV acceptor was found to be the important one responsible for the p-type conduction in both the nonirradiated and the e<sup>-</sup>-irradiated undoped materials annealed at temperatures up to 500 °C. This acceptor is not related to any  $V_{\text{Ga}}$ -related defect detected and is most likely the  $Ga_{\text{Sb}}$  antisite.

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